

In the claims:

1. (ORIGINAL) A silver alloy for use in a reflective film, comprising silver as a main element and at least one element as a first dopant element higher than silver in melting point.
2. (CURRENTLY AMENDED) The silver alloy for use in a reflective film according to claim 1, wherein the first dopant element is comprises at least any one of nickel and molybdenum.
3. (CURRENTLY AMENDED) The silver alloy for use in a reflective film according to claim 1, wherein the first dopant element is comprises at least any one of copper, cobalt, titanium, scandium, yttrium, manganese, silicon, iron, zirconium, niobium, tantalum and tungsten.
4. (CURRENTLY AMENDED) The silver alloy for use in a reflective film according to claim 1 any one of claims 1 to 3, comprising as a second dopant element at least one element selected from gallium, thulium and dysprosium.
5. (CURRENTLY AMENDED) The silver alloy for use in a reflective film according to claim 1 any one of claims 1 to 3, comprising as the a second dopant element at least one element selected from platinum, palladium, magnesium, zinc, terbium, gadolinium and erbium.
6. (CURRENTLY AMENDED) The silver alloy for use in a reflective film according to claim 1 any one of claims 1 to 3, comprising as the a second dopant element at least one element selected from gold, aluminum, neodymium, holmium, tin, bismuth and praseodymium.

7. (CURRENTLY AMENDED) The silver alloy for use in a reflective film according to claim 1 any one of claims 1 to 3, comprising as the a second dopant element at least one element selected from germanium, indium, samarium, ytterbium, strontium, boron, rhodium, iridium, ruthenium, chromium, lead, calcium, antimony, hafnium, lanthanum, cerium and europium.

8. (CURRENTLY AMENDED) The silver alloy for use in a reflective film according to claim 1 any one of claims 1 to 7, wherein a total of the concentration of the first dopant element and the concentration of the second dopant element are 0.01 to 5.0 atomic%.

9. (ORIGINAL) The silver alloy for use in a reflective film according to claim 8, wherein the total of the concentration of the first dopant element and the concentration of the second dopant element are 0.01 to 3.5 atomic %.

10. (CURRENTLY AMENDED) A sputtering target, comprising the silver alloy as defined in claim 1 any one of claims 1 to 9.

11. (NEW) An optical recording medium comprising a substrate and a silver alloy on the substrate which silver alloy comprises silver and at least one element as a first dopant element having a melting point higher than silver.

12. (NEW) The optical recording medium according to claim 11 wherein the silver alloy comprises a first dopant element comprising at least one of nickel and molybdenum.

13. (NEW) The optical recording medium according to claim 11 wherein the silver alloy comprises a first dopant element comprising at least one of copper, cobalt, titanium, scandium, yttrium, manganese, silicon, iron, zirconium, niobium, tantalum and tungsten.

14. (NEW) The optical recording medium according to claim 11 wherein the silver alloy comprises a second dopant element comprising at least one element selected from gallium, thulium and dysprosium.
15. (NEW) The optical recording medium according to claim 11 wherein the silver alloy comprises a second dopant element comprising at least one element selected from platinum, palladium, magnesium, zinc, terbium, gadolinium and erbium.
16. (NEW) The optical recording medium silver according to claim 11 wherein the silver alloy comprises a second dopant element comprising at least one element selected from gold, aluminum, neodymium, holmium, tin, bismuth and praseodymium.
17. (NEW) The optical recording medium according to claim 11 wherein the silver alloy comprises a second dopant element comprising at least one element selected from germanium, indium, samarium, ytterbium, strontium, boron, rhodium, iridium, ruthenium, chromium, lead, calcium, antimony, hafnium, lanthanum, cerium and europium.
18. (NEW) The optical recording medium according to claim 11 wherein a total of the concentration of the first dopant element and the concentration of the second dopant element in the silver alloy are 0.01 to 5.0 atomic%.
19. (NEW) The optical recording medium according to claim 11 wherein a total of the concentration of the first dopant element and the concentration of the second dopant element in the silver alloy are 0.01 to 3.5 atomic %.
20. (NEW) A method for producing an optical recording medium which comprises forming a film of a silver alloy on a substrate, which silver alloy comprises a first dopant element, selected from nickel, molybdenum, copper, cobalt, titanium, scandium, yttrium,

manganese, silicon, iron, zirconium, niobium, tantalum, and tungsten, which silver alloy optionally further comprises a second dopant element selected from gallium, thulium, dysprosium, platinum, palladium, magnesium, zinc, terbium, gadolinium, erbium, gold, aluminum, neodymium, holmium, tin, bismuth and praseodymium, germanium, indium, samarium, ytterbium, strontium, boron, rhodium, iridium, ruthenium, chromium, lead, calcium, antimony, hafnium, lanthanum, cerium and europium.